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7. (Amended) A method for producing an optical disk master, comprising the steps of:

- (a) providing a substrate having a photoresist film provided on a surface thereof;
- (b) rotating the substrate in a relative relationship with a beam;
- (c) irradiating the photoresist film on the substrate with the beam so as to form a first beam trace in the photoresist film;
- (d) further irradiating the photoresist film with the same beam such that the beam partially overlaps the first beam trace, so that a second beam trace is formed in the photoresist film; and
- (e) completing the optical disk master using the photoresist film.

Please add new claim 10 as follows:

10. (New) A method for producing an optical disk, comprising the steps of:

- (a) providing a substrate having a photoresist film provided on a surface thereof;
- (b) rotating the substrate in a relative relationship with a beam;
- (c) irradiating the photoresist film on the substrate with the beam so as to form a first beam trace in the photoresist film;
- (d) further irradiating the photoresist film with the same beam such that the beam partially overlaps the first beam trace, so that a second beam trace is formed in the photoresist film;
- (e) completing an optical disk master using the photoresist film; and
- (g) producing the optical disk using the optical disk master.

Attached hereto is an Appendix which includes the above-noted changes in annotated form.